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(71) Applicant: **ALPHALA CO., LTD.**; No. 83-2, Sec. 2, Chengde Rd., Datong Dist., Taipei City, 103 (TW).

(71) Applicant (for US only): **CHEN, Chung-Chin** [US/US]; 625 Slaters Lane, 4th Flr., Alexandria, Virginia 22314 (US).

(72) Inventors: **CHUNG, Cheng-Ho**; No. 83-2, Sec. 2, Chengde Rd. Datong Dist., Taipei City, 103 (TW). **TSENG, Shi-Liang**; No. 83-2, Sec. 2, Chengde Rd. Datong Dist., Taipei City, 103 (TW). **HSU, Hsiang-En**; No. 83-2, Sec. 2, Chengde Rd. Datong Dist., Taipei City, 103 (TW).

(74) Agent: **URCIA, Benjamin E.** et al.; 625 Slaters Lane, 4th Flr. 33805, Alexandria, Virginia 22314 (US).

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(54) Title: PROCESSES FOR PRODUCING AMIDE COMPOUNDS, AND THEIR CRYSTALLINE AND SALT FORM

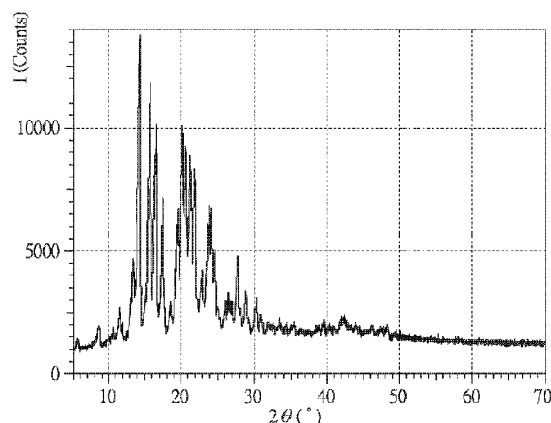
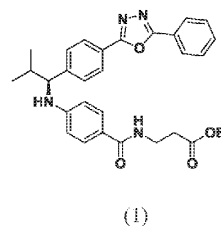


FIG. 1



(57) Abstract: Disclosed is processes for producing amide compounds, and their crystalline and salts form. Herein, one of the amide compounds is represented by the following formula (1): which is characterized by an X-ray diffraction (XRD) pattern having peaks at about 14.2, 15.6, 16.4, 20.1, 20.5 and 21.2° ± 0.2° 2θ.

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